

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	475	(semiconductor and (film or layer or surface) and (metal or catalyst) and (anneal\$3 or heat\$3) and (laser or light or beam or ray) and (getter\$3 or remov\$4)).CLM.	US-PGPUB	OR	ON	2005/07/20 11:41
L2	47	(semiconductor and (film or layer or surface) and (metal or catalyst) and (anneal\$3 or heat\$3) and (laser or light or beam or ray) and (getter\$3 or remov\$4) and (amorphous or noncrystalline) and (crystalliz\$5)). CLM.	US-PGPUB	OR	ON	2005/07/20 11:45